



US 20220399872A1

(19) **United States**(12) **Patent Application Publication**
Tani(10) **Pub. No.: US 2022/0399872 A1**(43) **Pub. Date: Dec. 15, 2022**(54) **COMPOSITE SUBSTRATE AND METHOD
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(JP)(21) Appl. No.: **17/818,040**(22) Filed: **Aug. 8, 2022****Related U.S. Application Data**(63) Continuation of application No. PCT/JP2022/
006547, filed on Feb. 18, 2022.(30) **Foreign Application Priority Data**

Jun. 11, 2021 (JP) 2021-097962

Publication Classification(51) **Int. Cl.****H03H 9/02** (2006.01)**H03H 3/08** (2006.01)**H01L 41/337** (2006.01)(52) **U.S. Cl.**CPC **H03H 9/02574** (2013.01); **H03H 9/02559**
(2013.01); **H03H 3/08** (2013.01); **H01L**
41/337 (2013.01)

(57)

ABSTRACT

A composite substrate according to includes: a support substrate; and a piezoelectric layer arranged on one side of the support substrate, wherein an amplitude of a waviness having a spatial frequency of more than 0.045 cyc/mm according to a shape of the support substrate is 10 nm or less.

